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Fig.2(a)

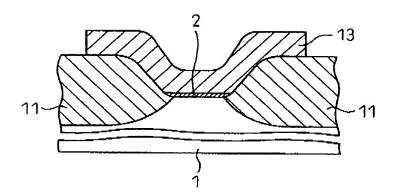


Fig. 2(b)

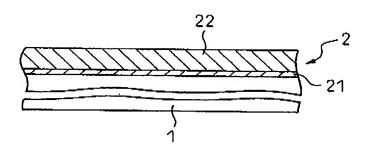


Fig.3

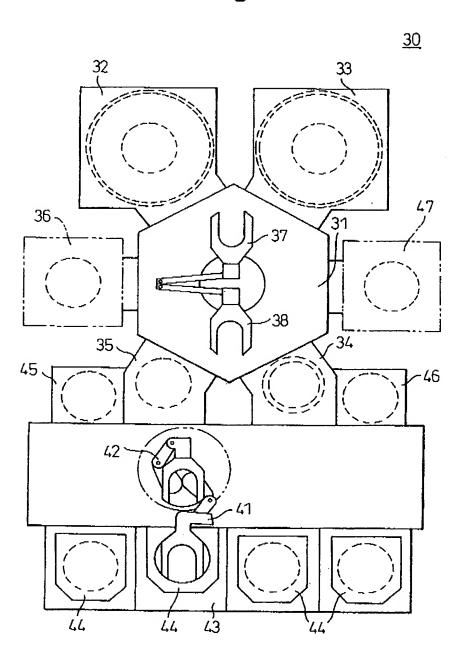


Fig. 4

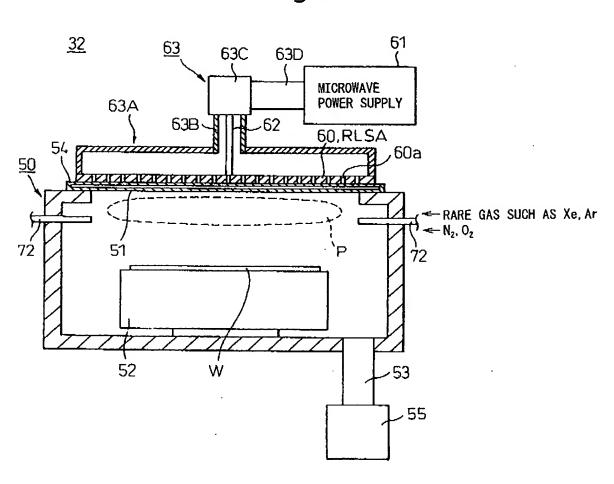
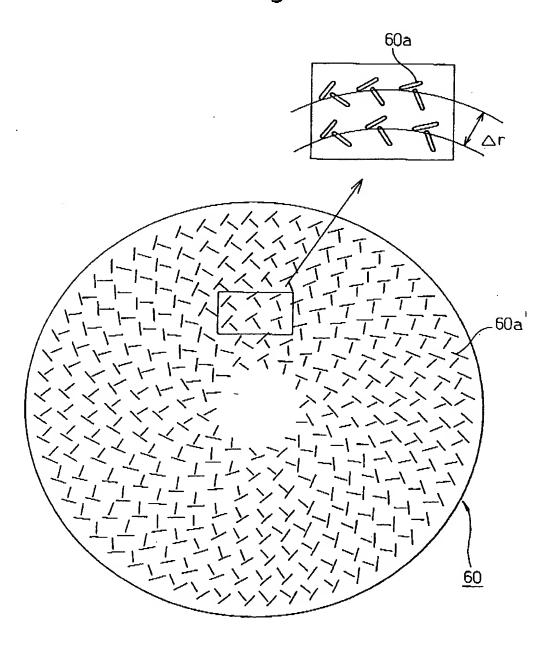


Fig.5



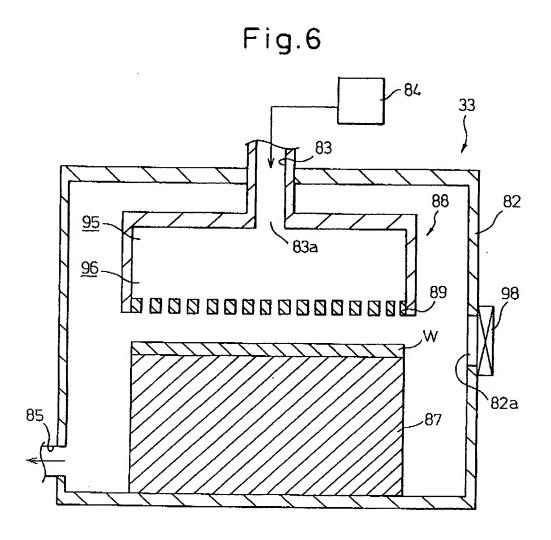


Fig.7A

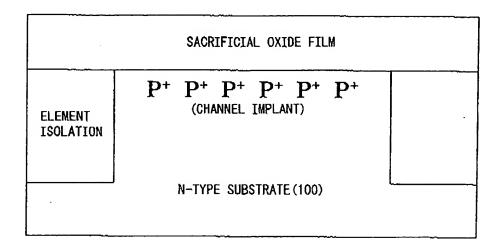
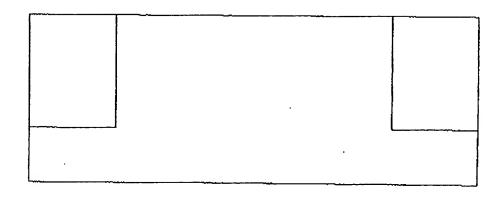


Fig.7B



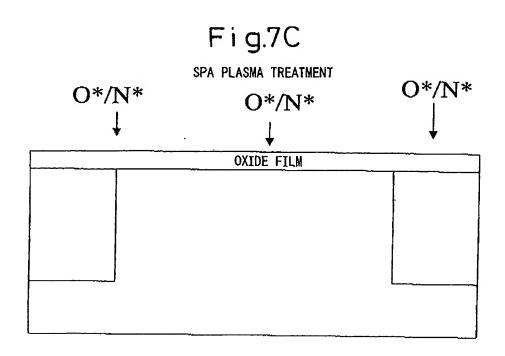


Fig.7D

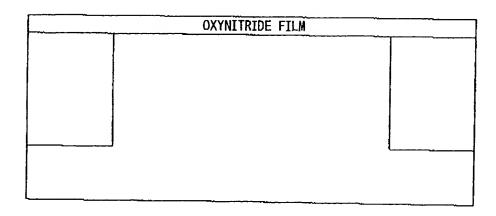


Fig.7E

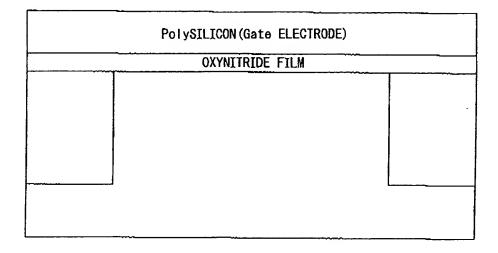
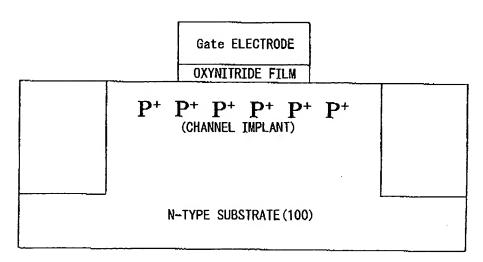


Fig.7F



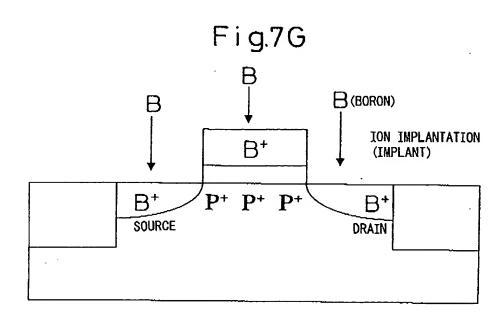


Fig.7H

METAL ELECTRODE

INTERLAYER INSULATING FILM

Gate

ELEMENT SOURCE CHANNEL DRAIN (CHANNEL)

(STI)

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Fig.8(a)

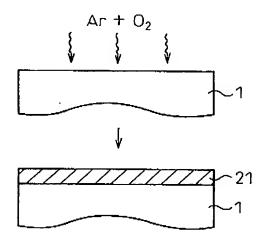


Fig.8(b)

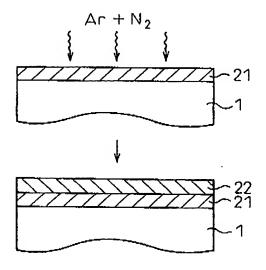
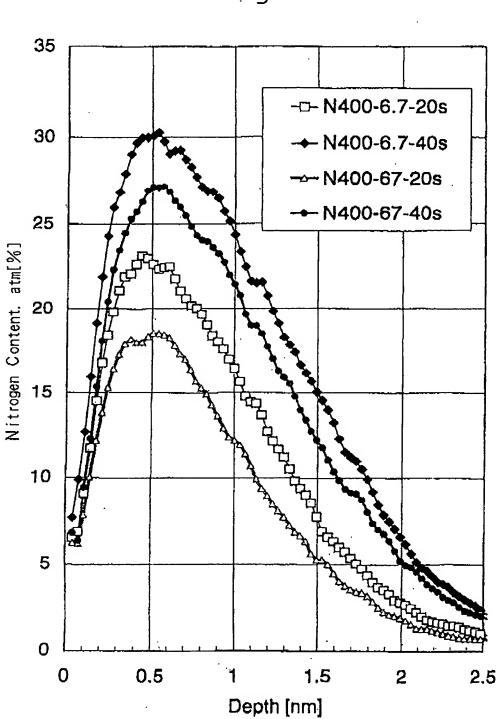


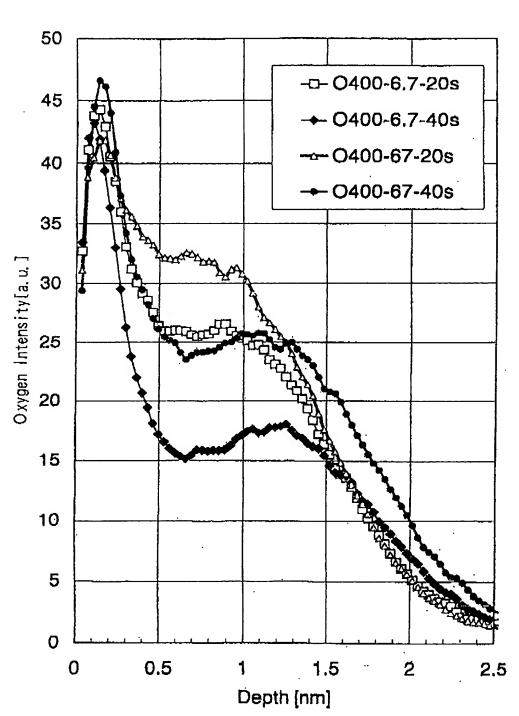
Fig.9



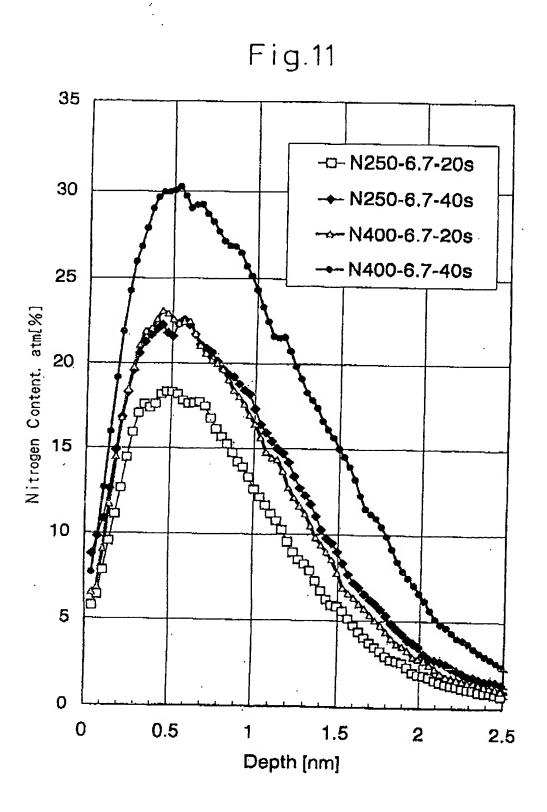
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PAGE 48/61 \* RCVD AT 9/28/2004 6:36:16 AM [Eastern Daylight Time] \* SVR:DCNTFAX01/0 \* DNIS:6285116 \* CSID:81354701911 \* DURATION (mm-ss):17-10

Fig.10

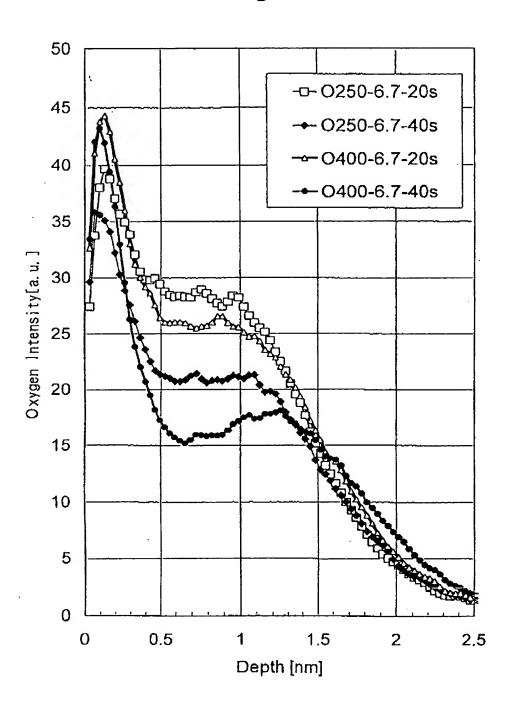


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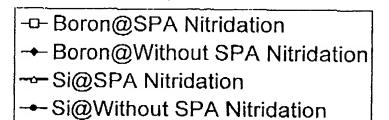
747 E
PAGE 50/61 \* RCVD AT 9/28/2004 6:36:16 AM [Eastern Daylight Time] \* SVR:DCNTFAX01/0 \* DNIS:6285116 \* CSID:81354701911 \* DURATION (mm-ss):17-10

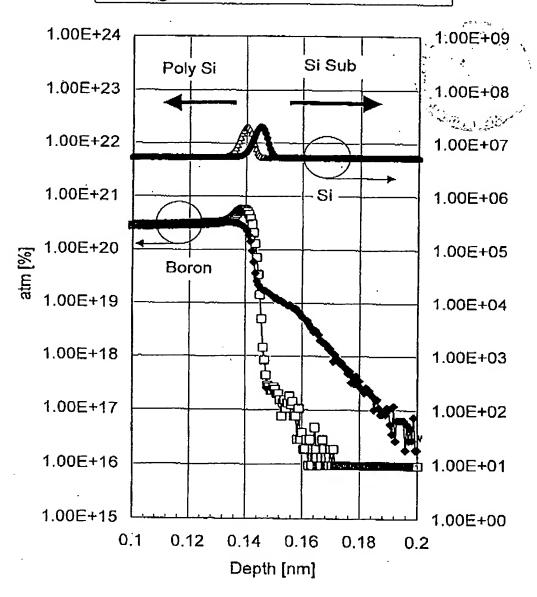
Fig.12



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Fig.13





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